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				Application Number	Not Yet Assigned
				Filing Date	
				First Named Inventor	Masahiko Ando
				Group Art Unit	N/A
				Examiner Name	Not Yet Assigned
Sheet	1	of	1	Attorney Docket Number	H6810.0011/P011

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U.S. PATENT DOCUMENTS						
Examiner Initials*	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
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K.N.	A	"Off Current Dependence on Fabrication Process of a Back-Channel-Etching-Type a-Si TFT" by Washizuka et al. (IDW 1997 pp. 207-210)	
K.N.	B	Nikkei Microdevices (June, 2000 p.175)	

Examiner Signature	<i>Khuemangayen</i>	Date Considered	10/31/02
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